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Oral presentation | 13 Semiconductors | 13.8 Compound and power electron devices and process technology

## [14a-B1-1~1]13.8 Compound and power electron devices and process technology

Seiji Nakamura(TMU)

Wed. Sep 14, 2016 11:45 AM - 12:15 PM B1 (Exhibition Hall)

△ : Presentation by Applicant for JSAP Young Scientists Presentation Award

▲ : English Presentation

▼ : Both of Above

No Mark : None of Above

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11:45 AM - 12:15 PM

### [14a-B1-1][JSAP Paper Award Speech] Characterization of electronic states at insulator/(Al)GaN interfaces for improved insulated gate and surface passivation structures of GaN-based transistors

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Keywords:JSAP Paper Award